



Call for Papers

ISPlasma2026/IC-PLANTS2026

18th International Symposium on Advanced Plasma Science and its Applications for Nitrides and Nanomaterials / 19th International Conference on Plasma-Nano Technology & Science

March 2-6, 2026
Meijo University
Nagoya, Japan

Related Fields

Plasma Science & Technologies

- Plasma Source
- Modeling & Simulation
- Plasma DX & AI
- Advanced Plasma Diagnostics
- Plasma with Liquid
- Thermal Plasma
- Thin Film Deposition Process
- Etching Process
- Atomic Layer Process
- Plasma for Nano & Green Technologies
- Flexible Electronics
- Aerospace / Space Applications

Wide Bandgap Semiconductors

- Crystal Growth
- Characterization
- Device Processing
- Optical and Optoelectronic Devices
- Electron & Power Devices

Nanomaterials

- Nanodots & Nanoparticles
- Nanotubes, Nanowires & Nanorods
- 2D Nanomaterials
- Porous Materials & Membranes
- Composite & Functionally Graded Materials
- Surface Modification & Functionalization
- Applications for Energy & Environment
- Nanomedicine & Sensing
- Nano Integration & Devices

Bio Applications

- Plasma Biology & Medicine
- Plasma Agriculture
- Biomaterials
- Biomarkers
- Bioimaging
- Bio-Devices, μ TAS, Lab on a Chip
- Biosensors
- Device Fabrication Technologies

ABSTRACT SUBMISSION DEADLINE: September 30, 2025
<http://www.isplasma.jp/>

Organizing Committee Chairperson:
Mineo Hiramatsu, Meijo University
Program Committee Chairperson:
Hiromasa Tanaka, Nagoya University
Executive Committee Chairperson:
Giichiro Uchida, Meijo University

Contact
Inter Group Corp.
Email: isplasma2026@intergroup.co.jp
Tel: +81-52-581-3241

This conference is sponsored by The Japan Society of Applied Physics

